

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Akira MATSUDA et al.

Art Unit: 1794

Application Number: 10/719,020 Examiner: Michael E. Lavilla

Filed: November 24, 2003 Confirmation Number: 9168

For: PLATING BATH FOR FORMING THIN RESISTANCE LAYER, METHOD OF

FORMATION OF RESISTANCE LAYER, CONDUCTIVE BASE WITH RESISTANCE LAYER, AND CIRCUIT BOARD MATERIAL WITH

RESISTANCE LAYER

Attorney Docket Number: 032130

Customer Number: 38834

<u>INFORMATION DISCLOSURE STATEMENT</u> <u>UNDER 37 C.F.R. §1.97(c)(1)/(e)(1)</u>

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450 June 25, 2008

Sir:

Applicants direct the attention of the Patent and Trademark Office to the documents listed on the attached Form PTO/SB/08. A copy of each non - U.S. document is attached.

Documents 1, 2, 4, and 5 were cited in an Office Action for a corresponding Chinese application. A copy of the Office Action is also enclosed.

Document 3 is a patent family member of document 5 and not directly cited in the Office Action.

This Information Disclosure Statement (IDS) is being submitted after issuance of a first official action on the merits and expiration of the three month period following the filing date or the entry of the national stage for the above-captioned application, but prior to issuance of either a final official action or a Notice of Allowance.

Information Disclosure Statement under 1.97(c)(1)
Attorney Docket No.: 032130

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citing the documents is attached.

The undersigned hereby certifies that each item of information contained in the IDS was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the IDS. A copy of the foreign communication

If there are any fees due in connection with the filing of this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP

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Enclosures:

Limited Recognition

PTO/SB/08 2 Documents

Foreign Communication



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